



Greetings Students,

The CJ 360: Inside Out Prison Exchange Program course will again be offered this Fall (2019). The Inside-Out Prison Exchange Program is an upper-level course which critically examines the intricacies of the criminal justice system. The course is comprised of 15 GVSU students and 15 inmates, and actually meets inside the prison. Examples of the topics to be covered include: theories of crime and punishment, what prisons are for, victimization, sentencing and punishment policies, and living in prison.

The class will be offered Fall 2019 on Tuesday afternoons from 1:00-3:50 p.m. Because the class meets at the Michigan Reformatory in Ionia (which is about 45 minutes away) you will need to be available beginning at 12:00pm on Tuesdays to travel to the prison. The class will end at approximately 3:30, and you should be back in Grand Rapids by about 4:30/5:00pm. Transportation is provided on your own, although students typically work together to organize a carpool.

I have attached an information flyer as well as the application. If you wish to apply, please be sure you meet the requirements (CJ major or minor, have taken CJ 101, 201, 330, etc. Preference will be given to students with a 2.8 GPA or above, but students near or below this will be considered if other components of their application meet or exceed other criteria). If you are interested, please submit your application to me (either via e-mail or to my office in 249C DeVos) no later than February 15th, 2019.

Please do not hesitate to contact me if you have any questions. If you are interested in hearing about the class before you decide to apply, I can put you in touch with some of the students who have taken the course in the past. Finally, please note that there are a limited number of seats available; the cap is 15 GVSU students and I have received more applications than open seats each semester, so the process is competitive. This is a “once in a lifetime” opportunity for a very unique classroom and learning experience – please consider applying!

Best,

J. Cwick